Title (en)

METHOD AND DEVICE FOR INCORPORATING A COMPOUND IN THE PORES OF A POROUS MATERIAL AND USES THEREOF

Title (de)

VERFAHREN UND VORRICHTUNG ZUR INKORPORIERUNG EINER VERBINDUNG IN DIE PORENEINES PORÖSEN MATERIALS UND DEREN ANWENDUNGEN

Title (fr)

PROCEDE ET DISPOSITIF D'INCORPORATION D'UN COMPOSE DANS LES PORES D'UN MATERIAU POREUX ET LEURS UTILISATIONS

Publication

EP 1511875 A2 20050309 (FR)

Application

EP 03757115 A 20030606

Priority

- FR 0301696 W 20030606
- FR 0207135 A 20020611

Abstract (en)

[origin: FR2840547A1] To incorporate a compound into the pores of a microporous or mesoporous material (30), obtained by a sol-gel process, it is contained within a transparent quartz chamber for vaporizing or sublimation at a temperature of at least 30degreesC and preferably at least 50degreesC up to 200degreesC. The compound is vaporized in a vacuum chamber (11), in the apparatus (10), and the porous material is frozen at a temperature at most-40degreesC before it is placed under a vacuum. For vaporizing, the chamber containing the compound and the porous material is heated by immersion in a heated oil bath, while the porous material is separated from the container base (13) by thermal insulation (14). The compound is a marker or a liquid coupled to a marker, a fluorophore, luminophore or a chromophore.

IPC 1-7

C23C 14/04; C23C 14/12

IPC 8 full level

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CPC (source: EP US)

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